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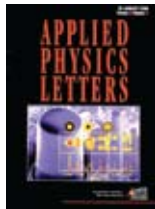
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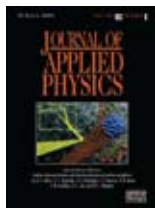
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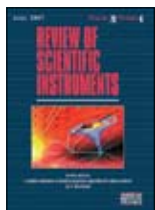
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Sources: Journal rankings and impact factor data from the ISI Journal Citation Report 2007 (published in June 2008, revised November 2008)  
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